## **BIOMARK Laboratories-INDIA**

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## **TECHNICAL SHEET**

B307 ROSE BENGAL AG	AR BASE						
Formula							
Ingredients:	gms/lit.						
Papaic digest of soyabean meal	5.00						
Dextrose	10.00						
Monopotassium phosphate	1.00						
Magnesium sulphate	0.50						
Rose bengal	0.05						
Agar	15.00						
Final pH (at 25°C): 7.2 <u>+</u> 0.2							
Directions :							
	distilled water. Heat to boiling to dissolve the media						
	at 15 lbs pressure (121°C) for 15 minutes. Cool to 40-45						
	phenicol Selective Supplement (BF004) for each 500 ml						
medium. Mix thoroughly and pour in	sterile Petri plates.						
Principle:							
	ovides the carbon and nitrogen sources required for go s. Dextrose is an energy source. Monopotassium phosph						
	esium sulphate provides necessary trace elements. Ro						
	ibits bacterial growth and restricts the size and height						
	molds. Rose bengal is taken up by yeast and mold coloni						
	and enumeration. Chloramphenicol Selective Supplementary						
(BF004) inhibit bacteria.							
QC Tests - (I)Dehydrated Medium							
Colour:	Light yellow to pink						
Appearance :	Homogeneous Free Flowing powder						
(II)Rehydrated medium							
pH (post autoclaving/heating):	7.2 ± 0.2						
Colour (post autoclaving/heating)	Deep pink						
Clarity (post autoclaving/heating)	Clear to slightly opalescent						
(III)Q.C. Test Microbiological							
	ter an incubation at 20-25°C for 5 days with added						
Chloramphenicol Selective Supple							
MICROORGANISM (ATCC )	GROWTH						
Aspergillus niger (16404 )	Good						
Candida albicans (10231 )	Good						
Escherichia coli (25922)	Inhibited						
Micrococcus luteus (10240)	Inhibited						
Saccharomyces cerevisiae (9763)	Good						
<b>Precautions:</b> 1. For Laboratory Us							
	2. Follow proper, established laboratory procedures in handling and disposing o						
	infectious materials.						
	1. Since the nutritional requirements of organisms vary, some strains may be						
	to grow or grow poorly on this medium.						
	2. Although this medium is selctive primarily for fungi, microscopic examination is						
	recommended for presumptive identification. Biochemical testing using pu						
cultures is required for complete identification.  3. Due to the selective properties of this medium and the type of specimen							
cultured, some stra	re properties of this medium and the type of specimen be ns of fungi may be encountered that fail to grow or gr lete medium; similarly, some strains of bacteria may						

encountered that are not inhibited or only partially inhibited.

Refer disclaimer Overleaf

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	4. Care should	be taken not to	expose this	medium to	light since		
	photodegradation of rose bengal yields compounds that are toxic to fungi.						
		ation enumeration o	f yeasts and	molds from 6	environmental		
	materials and food stuffs.						
Storage :	Dehydrated medium- below 30°C Prepared medium - Between 2 to 8°C.						
Packing:	500 gm. bottle						
Product profile:	Reconstitution	Quantity on	pH (25°C)	Supplement	Sterilization		
		Preparation (500g)					
B307	31.55 g/l	15.84 L	7.2 <u>+</u> 0.2	Chlorampheni			
				col selective	min.		
				supplement			
				(BF004)			

### Disclaimer:

User must ensure suitability of the product(s) in their application prior to use. Products conform solely to the information contained in this and other related BIOMARKLABORATORIES publications.

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Page 02 of 02

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